

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	Thomas Werner, et al	Examiner:	Daborah Chacko Davis
Serial No.:	10/691,274	Group Art Unit:	1756
Filed:	October 22, 2003	Att'y Docket:	2000.105300
For:	Technique For Reducing Resist Poisoning In Forming A Metallization Layer Including A Low-K Dielectric	Client Docket:	DE0302
		Confirmation No.:	4933

RESPONSE TO OFFICE ACTION DATED MARCH 26, 2007

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This paper is submitted in response to the Office Action dated March 26, 2007 for which the three-month date for response is June 26, 2007.

It is believed that no fee is due; however, should any fees under 37 C.F.R. §§ 1.16 to 1.21 be required for any reason, the Commissioner is authorized to deduct said fees from Williams, Morgan & Amerson, P.C. Deposit Account No. 50-0786/2000.105300.

Reconsideration of the application is respectfully requested.